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Emerging Smart Materials for Microelectromechanical Systems

Guest Editor:

Dr. Nathan Jackson

Nanoscience and Microsystems Engineering and Mechanical Engineering, University of New Mexico, Albuquerque, NM 87106, USA

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Message from the Guest Editor

Dear Colleagues,

The development of functional and multifunctional materials for the application of microelectromechanical systems (MEMS) is needed to enhance performance and create new transduction mechanisms for sensors and actuators. Enhancing material properties and developing methods of integrating and fabricating materials is the cornerstone to developing new MEMS devices. Accordingly, this Special Issue seeks to showcase research papers, short communications, and review articles that focus on the development of emerging functional and multifunctional materials for MEMS devices. This includes, but is not limited to, the development of new materials, enhancing material properties, developing new transduction mechanisms for materials, the integration of materials, new deposition techniques, or increasing manufacturing compatibility with MEMS. The Special Issue is interested in all types of functional materials, including 2D and thin films.













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Editor-in-Chief

Message from the Editor-in-Chief

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